

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Present Application:

Applicants : Shin Hwa Li and Annie Tissier
 Title : A SEMICONDUCTOR STRUCTURE HAVING AN IMPROVED
 PRE-METAL DIELECTRIC STACK AND METHOD FOR
 FORMING THE SAME
 Docket No. : 98-P-009 (850063.529)
 Date : August 3, 2000

Prior Application:

Examiner : Kurt Eaton
 Art Unit : 2823
 Application No. : 09/061,667

Box Patent Application
 Assistant Commissioner for Patents
 Washington, DC 20231

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents:

Please amend the above-identified application as follows:

In the Specification:

Amend the specification by inserting a new section before the "Technical Field"

as follows:

-- CROSS-REFERENCE TO RELATED APPLICATION

This application is a continuation of pending United States Patent Application No.

09/061,667, filed April 16, 1998. --

In the Claims:

1. (Amended) A semiconductor structure, comprising:
 a substrate;